



collaborating with world-class partners in better servicing various customers to enhance our leadership position in the China market. Currently, we are already producing CIS, Mobile CMMB, HDTV, RFID, and LCOS products for our Chinese customers and we expect our product portfolio to continue to strengthen.

In 2008, our total new customer tape outs increased 16% compared to the previous year. In the fourth quarter of 2008, new tape outs grew 9% year-over-year, and we expect new tape outs for the first quarter of 2009 to remain strong. In terms of our advanced technology development, we have achieved 45 nanometer silicon success ahead of schedule, and we released three of our own 65 nanometer standard cell libraries to our customers. Our Beijing fab DRAM conversion into logic capability has also been completed and now has a total capacity of 40,500 8-inch equivalent logic wafers per month.

In addition, we continue to strengthen our balance sheet. We have maintained positive EBITDA throughout the years, which we expect to continue into 2009. Our net cashflow from operations after deducting capital expenditure has increased to \$24 million in the fourth quarter of 2008 from negative \$121 million in the third quarter of 2008 as a result of a decrease in the use of working capital as well as tightened control over capital expenditure. As a result of the new equity funding from Datang and debt repayment, our debt equity ratio has improved to 39.7% as of the end of the fourth quarter as compared to 45.7% as of the end of the third quarter. We are also exercising tight capital expenditure and expense control during this downturn. We estimate that our capital expenditure for 2009 will be around \$190 million, representing approximately a 72% decline from 2008. In addition, we are targeting to reduce our payroll costs by 15% in 2009 without workforce reduction. We thank our employees for their support during this difficult time.

Under the current business environment, we plan to continue our focus on maintaining excellent customer relations, strengthening our product portfolio, focusing on the Greater China market, while continuing to develop advanced technology and reduce costs, in effort to position ourselves as a stronger and more competitive player in the foundry sector when the global economy recovers."

Conference Call / Webcast Announcement

Date: February 6, 2009

Time: 8:30 a.m. Shanghai time

Dial-in numbers and pass code: U.S. 1-617-597-5342 or HK 852-3002-1672 (Pass code: SMIC).

A live webcast of the 2008 fourth quarter announcement will be available at <http://www.smics.com> under the "Investor Relations" section. An archived version of the webcast, along with an electronic copy of this news release will be available on the SMIC website for a period of 12 months following the webcast.

About SMIC

Semiconductor Manufacturing International Corporation ("SMIC"; NYSE: SMI; SEHK: 981) is one of the leading semiconductor foundries in the world and the largest and most advanced foundry in Mainland China, providing integrated circuit (IC) foundry and technology services at 0.35um to 45nm. Headquartered in Shanghai, China, SMIC has a 300mm wafer fabrication facility (fab) and three 200mm wafer fabs in its Shanghai mega-fab, two 300mm wafer fabs in its Beijing mega-fab, a 200mm wafer fab in Tianjin, a 200mm fab under construction in Shenzhen, and an in-house assembly and testing facility in Chengdu. SMIC also has customer service and marketing offices in the U.S., Europe, and Japan, and a representative office in Hong Kong. In addition, SMIC manages and operates a 200mm wafer fab in Chengdu owned by Cension Semiconductor Manufacturing Corporation and a 300mm wafer fab in Wuhan owned by Wuhan Xinxin Semiconductor Manufacturing Corporation.

For more information, please visit www.smics.com



Safe Harbor Statements

(Under the Private Securities Litigation Reform Act of 1995)

This press release contains, in addition to historical information, “forward-looking statements” within the meaning of the “safe harbor” provisions of the U.S. Private Securities Litigation Reform Act of 1995. These forward-looking statements, including statements concerning SMIC’s ability to continue capturing growth opportunities in China, the quicker recovery of the Chinese economy relative to the global economy, SMIC’s expectation of becoming the primary supplier of silicon requirements for Datang’s TD-SCDMA technology, the continued strengthening of SMIC’s product portfolio, SMIC’s expectation that new tape outs in the first quarter of 2009 will remain strong, SMIC’s ability to maintain a positive EBITDA in 2009, SMIC’s expectations regarding the amount of its capital expenditures in 2009 and targeted reduction in payroll costs, SMIC’s efforts in positioning itself as a stronger and more competitive player in the foundry sector, and statements under “Depreciation and Amortization”, “Capex Summary” and “First Quarter 2009 Guidance”, are based on SMIC’s current assumptions, expectations and projections about future events. SMIC uses words like “believe,” “anticipate,” “intend,” “estimate,” “expect,” “project” and similar expressions to identify forward-looking statements, although not all forward-looking statements contain these words. These forward-looking statements are necessarily estimates reflecting the best judgment of SMIC’s senior management and involve significant risks, both known and unknown, uncertainties and other factors that may cause SMIC’s actual performance, financial condition or results of operations to be materially different from those suggested by the forward-looking statements including, among others, risks associated with cyclicity and market conditions in the semiconductor industry, the downturn in the global economy and the impact on China’s economy, intense competition, timely wafer acceptance by SMIC’s customers, timely introduction of new technologies, SMIC’s ability to capture growth opportunities in China, SMIC’s ability to become the primary supplier of silicon requirements for Datang’s TD-SCDMA technology, SMIC’s ability to strengthen its products portfolio, supply and demand for semiconductor foundry services, industry overcapacity, shortages in equipment, components and raw materials, orders or judgments from pending litigation, availability of manufacturing capacity and financial stability in end markets.

Investors should consider the information contained in SMIC’s filings with the U.S. Securities and Exchange Commission (SEC), including its annual report on 20-F, as amended, filed with the SEC on November 28, 2008, especially in the “Risk Factors” and “Management’s Discussion and Analysis of Financial Condition and Results of Operations” sections, and such other documents that SMIC may file with the SEC or SEHK from time to time, including on Form 6-K. Other unknown or unpredictable factors also could have material adverse effects on SMIC’s future results, performance or achievements. In light of these risks, uncertainties, assumptions and factors, the forward-looking events discussed in this press release may not occur. You are cautioned not to place undue reliance on these forward-looking statements, which speak only as of the date stated, or if no date is stated, as of the date of this press release. Except as required by law, SMIC undertakes no obligation and does not intend to update any forward-looking statement, whether as a result of new information, future events or otherwise.

Material Litigation

Recent TSMC Legal Developments:

On August 25, 2006, TSMC filed a lawsuit against the Company and certain subsidiaries (SMIC (Shanghai), SMIC (Beijing) and SMIC (Americas)) (7:08-cv-00660 (2008) 08-24762 (e) 8.0298832163 (022386947497502)



In the present litigation, TSMC alleges that the Company has incorporated TSMC trade secrets in the manufacture of the Company's 0.13 micron or smaller process products. TSMC further alleges that as a result of this claimed breach, TSMC's patent license is terminated and the covenant not to sue is no longer in effect with respect to the Company's larger process products.

The Company has vigorously denied all allegations of misappropriation. The Court has made no finding that TSMC's claims are valid. The Court has set a trial date of September 1, 2009.

On September 13, 2006, the Company announced that in addition to filing a response strongly denying the allegations of TSMC in the United States lawsuit, it filed on September 12, 2006, a cross-complaint against TSMC seeking, among other things, damages for TSMC's breach of contract and breach of implied covenant of good faith and fair dealing.

On November 16, 2006, the High Court in Beijing, the People's Republic of China, accepted the filing of a complaint by the Company and its wholly-owned subsidiaries, SMIC (Shanghai) and SMIC (Beijing), regarding the unfair competition arising from the breach of bona fide (i.e. integrity, good faith) principle and commercial defamation by TSMC ("PRC Complaint"). In the PRC Complaint, the Company is seeking, among other things, an injunction to stop TSMC's infringing acts, public apology from TSMC to the Company and compensation from TSMC to the Company, including profits gained by TSMC from their infringing acts.

TSMC filed with the California court in January 2007 a motion seeking to enjoin the PRC action. In February 2007, TSMC filed with the Beijing High Court a jurisdictional objection, challenging the competency of the Beijing High Court's jurisdiction over the PRC action.

In March 2007, the California Court denied TSMC's motion to enjoin the PRC action. TSMC appealed this ruling to California Court of Appeal. On March 26, 2008, the Court of Appeal, in a written opinion, denied TSMC's appeal.

In July 2007, the Beijing High Court denied TSMC's jurisdictional objection and issued a court order holding that the Beijing High Court shall have proper jurisdiction to try the PRC action. TSMC appealed this order to the Supreme Court of the People's Republic of China. On January 7, 2008, the Supreme Court heard TSMC's appeal. On June 13, 2008, the Supreme Court denied TSMC's appeal and affirmed the jurisdiction of the Beijing High Court.

On August 14, 2007, the Company filed an amended cross-complaint against TSMC seeking, among other things, damages for TSMC's breach of contract and breach of patent license agreement. TSMC thereafter denied the allegations of the Company's amended cross-complaint and subsequently filed additional claims that the Company breached the Settlement Agreement by filing an action in the Beijing High Court. The Company has denied these additional claims by TSMC.

On August 15-17, 2007, the California Court held a preliminary injunction hearing on TSMC's motion to enjoin use of certain process recipes in certain of the Company's 0.13 micron logic process flows.

On September 7, 2007, the Court denied TSMC's preliminary injunction motion, thereby leaving unaffected the Company's development and sales. However, the court required the Company to provide 10 days' advance notice to TSMC if the Company plans to disclose logic technology to non-SMIC entities under certain circumstances, to allow TSMC to object to the planned disclosure.

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On June 23, 2008, the Company filed in the California court a cross-complaint against TSMC seeking, among other things, damages for TSMC's unlawful misappropriation of trade secrets from SMIC to improve its competitive position against SMIC.

On July 10, 2008, the California Court held a preliminary injunction hearing on TSMC's motion to enjoin disclosure of information on certain process recipes in the Company's 0.30 micron logic process flows to 3rd parties. On August 8, 2008, the Court granted-in-part TSMC's motion and preliminarily enjoined SMIC from disclosing fourteen 0.30 μm process steps. On October 3, 2008, SMIC filed a notice of appeal of the Court's August 8, 2008 Order with the California Court of Appeal.

During the pre-trial proceedings in the matter, questions have arisen regarding the actual terms of the 2005 Settlement Agreement between SMIC and TSMC, and regarding whether a valid agreement was executed by the parties. In light of recent disclosures made in the case, SMIC is now of the view that the Settlement Agreement attached as an exhibit to the Company's 2005 Form 20-F does not correctly reflect the terms of an agreement between the parties. From January 13-16, 2009, the California Superior Court held trial to determine (a) if a valid agreement exists between the parties and, if so, (b) the terms of such agreement. When issued, these determinations might materially impact our financial statements and our financial position and results of operations both historically and prospectively.

The Court has scheduled a trial upon all liability issues related to a selected list of TSMC trade secret claims and SMIC trade secret claims to commence on September 1, 2009.

Under the provisions of SFAS 144, the Company is required to make a determination as to whether or not this pending litigation represents an event that requires a further analysis of whether the patent license portfolio has been impaired. We believe that the lawsuit is at a preliminary stage and we are still evaluating whether or not the litigation represents such an event. The Company expects further information to become available to us, which will aid us in making a determination. The outcome of any impairment analysis performed under SFAS 144 might result in a material impact to our financial position and results of operations. Because the case is in its preliminary stage, the Company is unable to evaluate the likelihood of an unfavorable outcome or to estimate the amount or range of potential loss.



Summary of Fourth Quarter 2008 Operating Results

Amounts in US\$ thousands, except for EPS and operating data

	4Q08	3Q08	QoQ	4Q07	YoY
Revenue	272,479	375,945	-27.5%	395,254	-31.1%
Cost of sales	347,114	348,721	-0.5%	360,207	-3.6%
Gross profit	(74,635)	27,224	-	35,047	-
Operating expenses	46,445	40,451	14.8%	57,389	-19.1%
Loss from operations	(121,080)	(13,227)	815.4%	(22,342)	441.9%
Other expenses, net	(4,146)	(15,631)	-73.5%	(1,655)	150.5%
Income tax (expenses) credit	(745)	(4,499)	-83.4%	23,100	-
Net loss after income taxes	(125,971)	(33,357)	277.6%	(897)	13943.6%
Minority interest	1,520	3,094	-50.9%	1,157	31.4%
Loss from equity investment	(92)	(26)	253.8%	(882)	-89.5%
Loss attributable to holders of ordinary shares	(124,543)	(30,289)	311.2%	(622)	19923.0%
Gross margin	-27.4%	7.2%		8.9%	
Operating margin	-44.4%	-3.5%		-5.7%	
Net (loss) income per ordinary share - basic ⁽¹⁾	(0.0066)	(0.0016)		(0.0000)	
Net (loss) income per ADS – basic	(0.3287)	(0.0814)		(0.0017)	
Net (loss) income per ordinary share – diluted ⁽¹⁾	(0.0066)	(0.0016)		(0.0000)	
Net (loss) income per ADS – diluted	(0.3287)	(0.0814)		(0.0017)	
Wafers shipped (in 8" wafers) ⁽²⁾	323,175	431,660	-25.1%	497,454	-35.0%
Capacity utilization	67.7%	90.5%		94.4%	

Note:

⁽¹⁾ Based on weighted average ordinary shares of 18,948 million (basic) and 18,948 million (diluted) in 4Q08, 18,612 million (basic) and 18,612 million (diluted) in 3Q08 and 18,550 million (basic) and 18,550 million (diluted) in 4Q07

⁽²⁾ Including copper interconnects

Overall revenue decreased to \$272.5 million in 4Q08, down 27.5% QoQ from \$375.9 million in 3Q08 and down 31.1% YoY from \$395.3 million in 4Q07 due to lower wafer shipments.

Cost of sales decreased to \$347.1 million in 4Q08, down 0.5% QoQ from \$348.7 million in 3Q08.

Gross profit decreased to -\$74.6 million in 4Q08, down QoQ from \$27.2 million in 3Q08 and down YoY from \$35.0 million in 4Q07.

Gross margins decreased to -27.4% in 4Q08 from 7.2% in 3Q08 due to a significant drop in fab utilization.

Total operating expenses increased to \$46.4 million in 4Q08 from \$40.5 million, an increase of 14.8% QoQ primarily due to higher amortization of acquired IP-related intangible assets.

R&D expenses decreased to \$12.5 million in 4Q08, down 29.8% from \$17.8 million, primarily due to an increase in government subsidies received in 4Q08. Excluding the government subsidies, R&D expenses increased 8.0% QoQ due to the expenses related to 45nm and 65nm R&D activities.



G&A expenses increased to \$16.1 million in 4Q08 from \$10.8 million in 3Q08 due to reversal of overprovision of legal fee in 3Q08, higher professional fees, and higher doubtful debt provision in 4Q08.

Selling & marketing expenses increased to \$5.8 million in 4Q08, up 4.8% QoQ from \$5.6 million in 3Q08.



Analysis of Revenues

Sales Analysis			
By Application	4Q08	3Q08	4Q07
Computer	4.5%	5.4%	22.9%
Communications	45.9%	53.0%	47.4%
Consumer	37.5%	32.8%	22.7%
Others	12.1%	8.8%	7.0%
By Service Type	4Q08	3Q08	4Q07
Logic ⁽³⁾	85.6%	87.4%	67.4%
DRAM	2.6%	2.4%	23.6%
Management Services	2.2%	2.4%	1.5%
Mask Making, testing, others	9.6%	7.9%	7.5%
By Customer Type	4Q08	3Q08	4Q07
Fabless semiconductor companies	65.0%	55.1%	49.3%
Integrated device manufacturers (IDM)	15.2%	26.1%	38.5%
System companies and others	19.8%	18.8%	12.2%
By Geography	4Q08	3Q08	4Q07
North America	59.9%	58.6%	44.6%
Asia Pacific (ex. Japan)	36.0%	34.6%	26.4%
Japan	1.7%	2.1%	10.4%
Europe	2.4%	4.7%	18.6%
Wafer Revenue Analysis			
By Technology (logic, DRAM & copper interconnect only)	4Q08	3Q08	4Q07
0.09μm	11.1%	19.4%	25.3%
0.13μm	34.4%	25.1%	24.4%
0.15μm	2.2%	2.0%	5.5%
0.18μm	32.5%	33.9%	28.3%
0.25μm	0.6%	0.5%	0.5%
0.35μm	19.2%	19.1%	16.0%
By Technology (Logic Only) ⁽¹⁾	4Q08	3Q08	4Q07
0.09μm	10.9%	19.4%	7.7%
0.13μm ⁽²⁾	32.6%	23.2%	21.0%
0.15μm	2.2%	2.0%	7.7%
0.18μm	33.7%	35.0%	40.3%
0.25μm	0.7%	0.5%	0.6%
0.35μm	19.9%	19.9%	22.7%

Note:

(1) Excluding 0.13μm copper interconnects

(2) Represents revenues generated from manufacturing full flow wafers

(3) Including 0.13μm copper interconnects



Capacity*

Fab / (Wafer Size)	4Q08	3Q08
Shanghai Mega Fab (8") ⁽¹⁾	88,000	88,000
Beijing Mega Fab (12") ⁽²⁾	40,500	36,000
Tianjin Fab (8")	32,000	30,000
Total monthly wafer fabrication capacity	160,500	154,000

Note:

* Wafers per month at the end of the period in 8" wafers

(1) Shanghai Mega Fab is now comprised of Fab 1, Fab 2, and Fab 3

(2) Beijing Mega Fab is now comprised of Fab 4, Fab 5, and Fab 6

Shipment and Utilization

8" equivalent wafers	4Q08	3Q08	4Q07
Wafer shipments including copper interconnects	323,175	431,660	497,454
Utilization rate ⁽¹⁾	67.7%	90.5%	94.4%

Note:

(1) Capacity utilization based on total wafer out divided by estimated capacity

Wafer shipments decreased 25.1% QoQ to 323,175 units of 8-inch equivalent wafers in 4Q08 from 431,660 units of 8-inch equivalent wafers in 3Q08, and down 35.0% YoY from 497,454 8-inch equivalent wafers in 4Q07.

For the full year of 2008, the overall wafer shipments were 1,611,208 units of 8-inch equivalent wafers, down 12.9% YoY while logic only wafer shipments increased 24.9% YoY.



Detailed Financial Analysis

Gross Profit Analysis

<i>Amounts in US\$ thousands</i>	4Q08	3Q08	QoQ	4Q07	YoY
Cost of sales	347,114	348,721	-0.5%	360,207	-3.6%
Depreciation	183,916	165,641	11.0%	161,232	14.1%
Other manufacturing costs	156,446	176,329	-11.3%	190,671	-18.0%
Deferred cost amortization	5,886	5,886	-	5,886	-
Share-based compensation	866	865	0.1%	2,418	-64.2%
Gross Profit	(74,636)	27,224	-	35,047	-
Gross Margin	-27.4%	7.2%		8.9%	

Cost of sales decreased to \$347.1 million in 4Q08, down 0.5% QoQ from \$348.7 million in 3Q08.

Depreciation increased in 4Q08 primarily due to low fab utilization resulting in most of the depreciation being expensed in the same quarter instead of being capitalized as inventory costs.

Gross profit decreased to -\$74.6 million in 4Q08, down QoQ from \$27.2 million in 3Q08 and down YoY from \$35.0 million in 4Q07.

Gross margins decreased to -27.4% in 4Q08 from 7.2% in 3Q08 due to a significant drop in fab utilization.

Operating Expense Analysis

<i>Amounts in US\$ thousands</i>	4Q08	3Q08	QoQ	4Q07	YoY
Total operating expenses	46,445	40,451	14.8%	57,389	-19.1%
Research and development	12,524	17,838	-29.8%	26,201	-52.2%
General and administrative	16,146	10,761	50.0%	18,820	-14.2%
Selling and marketing	5,843	5,578	4.8%	5,688	2.7%
Amortization of intangible assets	11,564	6,906	67.4%	6,878	68.1%
Impairment loss of long-lived assets	967	-	-	-	-
Income from disposal of properties	(599)	(632)	-5.2%	(198)	202.5%

Total operating expenses increased to \$46.4 million in 4Q08 from \$40.5 million, an increase of 14.8% QoQ primarily due to an increase in the amortization of acquired IP-related intangible assets.

R&D expenses decreased to \$12.5 million in 4Q08, down 29.8% from \$17.8 million primarily due to an increase in government subsidies received in 4Q08. Excluding government subsidies, R&D expenses increased 8.0% QoQ due to higher expenses related to 45nm and 65nm R&D activities.

G&A expenses increased to \$16.1 million in 4Q08 from \$10.8 million in 3Q08 due in part to a reversal of overprovision of legal fees recorded in 3Q08, higher professional fees, and higher doubtful debt provision in 4Q08.

Selling & marketing expenses increased to \$5.8 million in 4Q08, up 4.8% QoQ from \$5.6 million in 3Q08.



Other Income (Expenses)

Amounts in US\$ thousands	4Q08	3Q08	QoQ	4Q07	YoY
Other income (expenses)	(4,146)	(15,631)	-73.5%	(1,655)	150.5%
Interest income	1,184	2,542	-53.4%	3,971	-70.2%
Interest expense	(7,133)	(11,088)	-35.7%	(11,485)	-37.9%
Foreign currency exchange gain (loss)	(2,543)	(7,023)	-63.8%	4,613	-
Other, net	4,346	(62)	-	1,246	248.8%

Interest expense decreased in 4Q08 relative to 3Q08 primarily due to an increase in government interest subsidies received, the effect of which was partially offset by a decrease in interest capitalization resulting from lower capital expenditure. Excluding the effect from government subsidies and interest capitalization, interest expense in 4Q08 increased by \$1.1 million from 3Q08.

Foreign exchange loss arising from non-operating activities has decreased to \$2.5 million in 4Q08 from \$7.0 million in 3Q08. Combined with the foreign exchange gain arising from the operating activities (separately recorded under the G&A expenses), the Company recorded an overall foreign exchange loss of \$0.4 million in 4Q08 as compared to a foreign exchange loss of \$4.6 million in 3Q08.

Depreciation and Amortization

Total depreciation and amortization for 4Q08 is \$207.7 million as compared to \$197.7 million for 3Q08.

Total depreciation and amortization for 2008 is \$805.6 million as compared to \$754.0 million for 2007.

The total depreciation and amortization for 2009 is expected to remain flat as compared to 2008, but total depreciation and amortization is expected to decline in 2010 as the majority of the 8-inch production equipment in our Shanghai Mega Fab will reach the end of the depreciation life in 2010.

Liquidity

Amounts in US\$ thousands	4Q08	3Q08
Cash and cash equivalents	450,230	392,881
Restricted Cash	6,255	3,000
Short term investments	19,928	50,646
Accounts receivable	199,372	285,874
Inventory	171,637	233,022
Others	79,437	72,272
Total current assets	926,859	1,037,695
Accounts payable	185,919	301,712
Short-term borrowings	201,258	212,600
Current portion of long-term debt	360,629	340,355
Others	151,967	177,736



Total current liabilities	899,773	1,032,403
Cash Ratio	0.5x	0.3x
Quick Ratio	0.7x	0.7x
Current Ratio	1.0x	1.0x

The increase in cash and cash equivalents as of end of 4Q08 was primarily due to \$165.1 million of new equity funding raised during the quarter from a strategic investor.

Capital Structure

<i>Amounts in US\$ thousands</i>	4Q08	3Q08
Cash and cash equivalents	450,230	392,881
Restricted Cash	6,255	3,000
Short-term investment	19,928	50,646
Current portion of promissory note	29,242	29,493
Promissory note	23,590	37,762
Short-term borrowings	201,258	212,600
Current portion of long-term debt	360,629	340,355
Long-term debt	536,518	692,131
Total debt	1,098,405	1,245,086
Shareholders' equity	2,764,279	2,721,561
Total debt to equity ratio	39.7%	45.7%



Capex Summary

Capital expenditures for 4Q08 were \$56 million. The total capital expenditure for 2008 was approximately \$665 million as compared to the earlier market guidance of \$790 million. Total planned capital expenditures for 2009 will be around \$190 million.

First Quarter 2009 Guidance

The following statements are forward looking statements which are based on current expectation and which involve risks and uncertainties, some of which are set forth under "Safe Harbor Statements" above.

Given the lack of visibility in this current market environment, we are unable to provide specific revenue guidance. However, we estimate that Q109 revenue may decline by approximately 50%.

Operating expenses excluding foreign exchange difference ranging from \$53 million to \$56 million.

Capital expenditure expected to be approximately \$40 million to \$45 million.

Depreciation and amortization expected to be approximately \$206 million to \$208 million.



Recent Highlights and Announcements

Litigation Update [2008-12-24]

Unusual Increase in Share Trading Price [2008-12-24]

SMIC Achieves First 45-nanometer Silicon Success [2008-12-8]

Datang Holdings to Invest US\$172 Million in SMIC [2008-11-10]

Issue of New Ordinary Shares under General Mandate and Resumption of Trading [2008-11-10]

Suspension of Trading [2008-11-06]

SMIC Reports Results for the Three Months Ended September 30, 2008 [2008-10-29]

SMIC Received U.S. Export Licenses for 32nm Technologies [2008-10-27]

SMIC Successfully Develops 0.11 Micron CIS Process Technology [2008-10-23]

HDIC Cooperates with SMIC for Successful Debut of High Definition TV Transmission Chips during Beijing Olympic Games [2008-10-14]

Change in Directorate [2008-10-06]

Please visit SMIC's website at http://www.smics.com/website/enVersion/Press_Center/pressRelease.jsp for further details regarding the recent announcements.



Semiconductor Manufacturing International Corporation
BALANCE SHEET
(In US dollars)

As of the end of	
December 31, 2008	September 30, 2008
(Unaudited)	(Unaudited)

ASSETS

Current assets:



Semiconductor Manufacturing International Corporation
BALANCE SHEET
(In US dollars)

Ordinary shares, \$0.0004 par value, 50,000,000,000 shares authorized, shares issued and outstanding 22,327,784,827 and 18,619,884,481 at December 31, 2008 and September 30, 2008, respectively	8,931,114	7,447,954
Additional paid-in capital	3,489,382,267	3,323,364,177
Accumulated other comprehensive loss	(439,123)	(199,305)
Accumulated deficit	(733,595,719)	(609,051,735)
Total stockholders' equity	2,764,278,539	2,721,561,091
TOTAL LIABILITIES AND STOCKHOLDERS' EQUITY	\$ 4,270,621,822	\$ 4,541,917,475



Semiconductor Manufacturing International Corporation
CONSOLIDATED STATEMENT OF CASH FLOWS
(In US dollars)

	For the three months ended	
	December 31, 2008	September 30, 2008
	(Unaudited)	(Unaudited)
Operating activities		
Net loss	(124,543,984)	(30,289,138)
Adjustments to reconcile net loss to net cash provided by (used in) operating activities:		
Minority interest	(1,519,951)	(3,094,474)
Deferred tax	(1,924,575)	511,663
Gain on disposal of plant and equipment	(598,820)	(632,029)
Depreciation and amortization	193,779,737	188,387,781
Amortization of acquired intangible assets	11,563,678	6,931,344
Share-based compensation	2,358,942	2,368,706
Non cash interest expense on promissory notes	1,480,674	1,522,485
Loss from equity investment	92,320	25,803
Impairment loss of acquired intangible assets	966,667	-
Changes in operating assets and liabilities:		
Accounts receivable, net	86,502,133	(23,455,351)
Inventories	61,385,789	19,371,201
Prepaid expense and other current assets	(5,798,142)	(9,608,778)
Accounts payable	(36,579,576)	(57,377,721)
Accrued expenses and other current liabilities	(15,985,881)	15,422,174
Income tax payable	34,327	35,418
Net cash provided by operating activities	171,213,338	110,119,084
Investing activities:		
Purchases of property and equipment		



Semiconductor Manufacturing International Corporation
CONSOLIDATED STATEMENT OF CASH FLOWS
(In US dollars)

Net cash provided by (used in) financing activities	6,460,206	(34,668,075)
Effect of exchange rate changes	(239,821)	(62,231)
NET INCREASE (DECREASE) IN CASH AND CASH EQUIVALENTS	57,348,549	(87,384,370)
CASH AND CASH EQUIVALENTS, beginning of period	392,881,020	480,265,390
CASH AND CASH EQUIVALENTS, end of period	450,229,569	392,881,020